

# Stimulated Light Emission of Silicon Photomultipliers

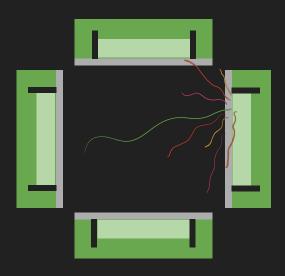
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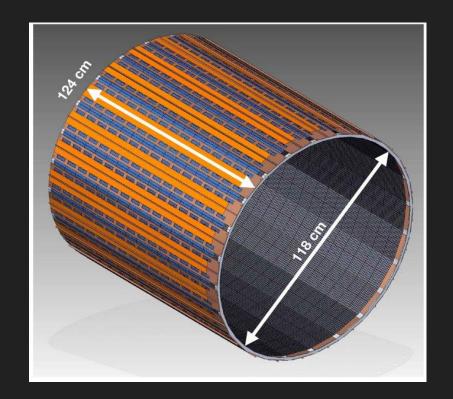
Joe McLaughlin, Seraphim Koulosousas, Jocelyn Monroe (RHUL, UK)

Paolo Agnes, Priyanka Kachru (GSSI, Italy)

# SPAD and Crosstalk Reabsorption Internal Crosstalk **External Crosstalk** SiO Active Region

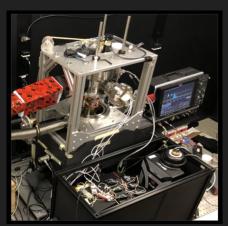
## The Problem:

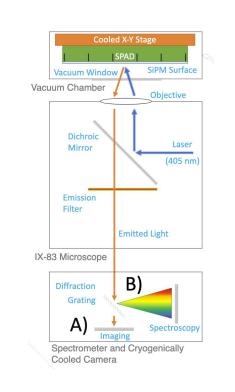




#### Microscope for the Injection and Emission of Light





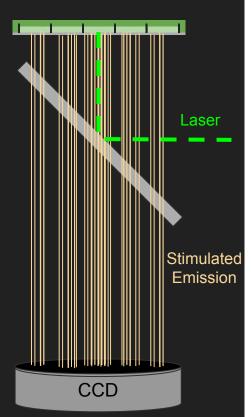


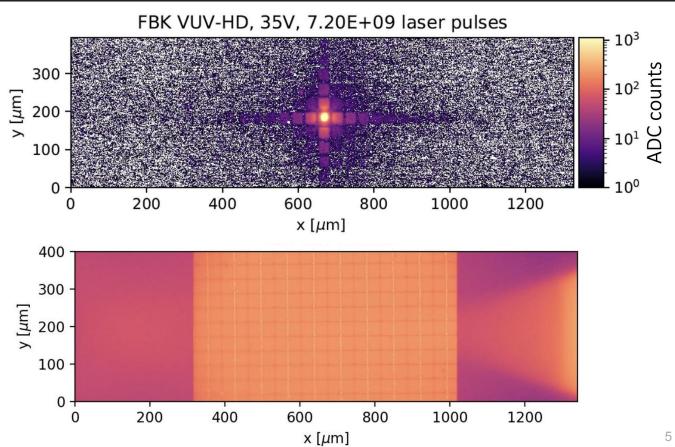
Cryo CCD Camera Spectrometer

4x-50x microscope magnification Sub μm precision xy translation

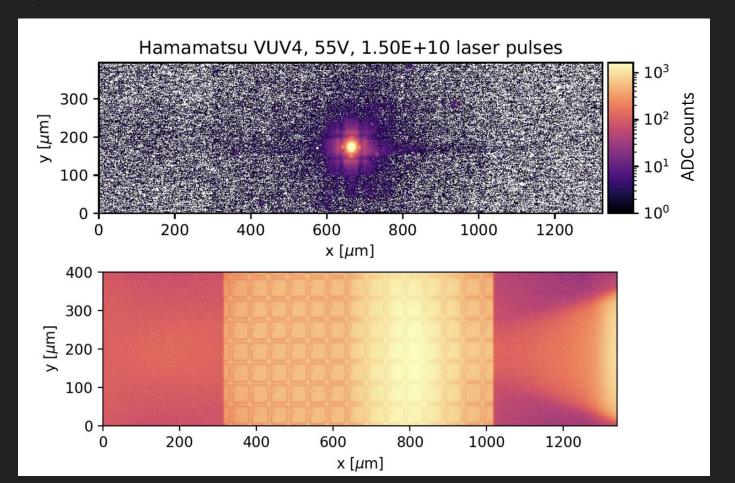
LN2 PID Cryocontroller (down to LAr/LXe temps)

#### FBK VUV-HD3

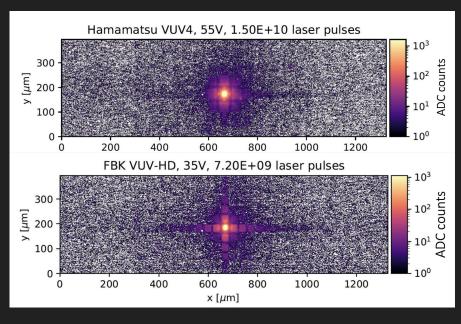




#### HPK VUV4

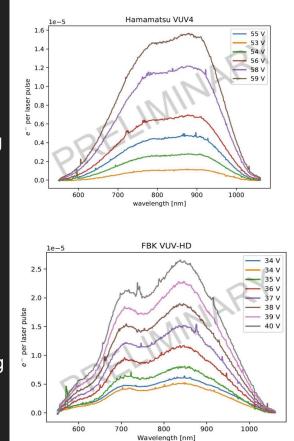


#### HPK vs FBK

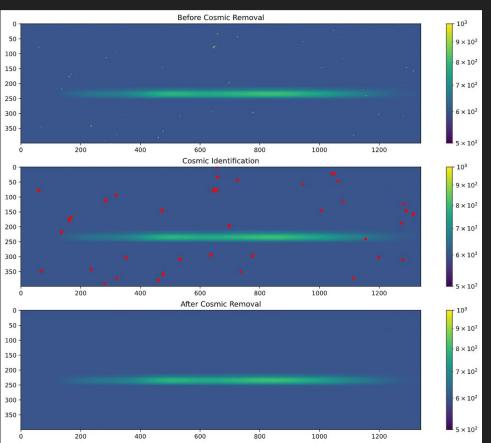


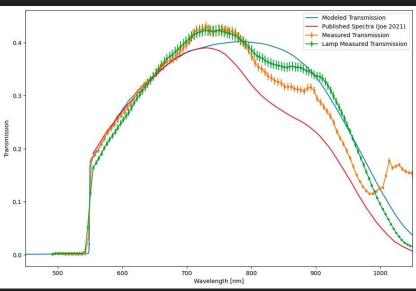
Tungsten trench
Photon absorption
Thin surface coating

Polysilicon trench More reflection SiO<sub>2</sub> surface coating

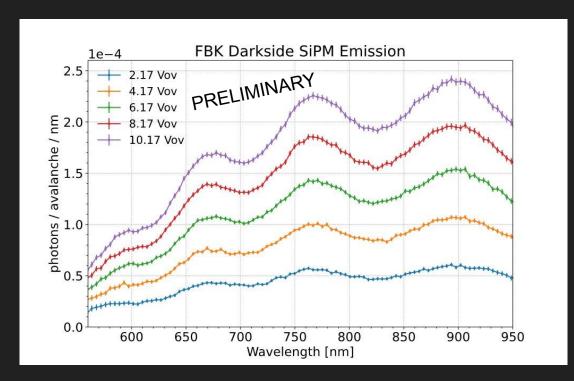


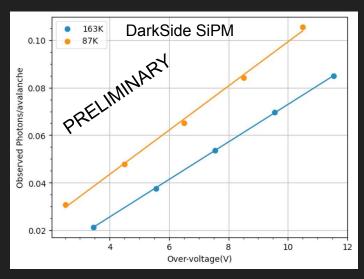
# Analysis Process



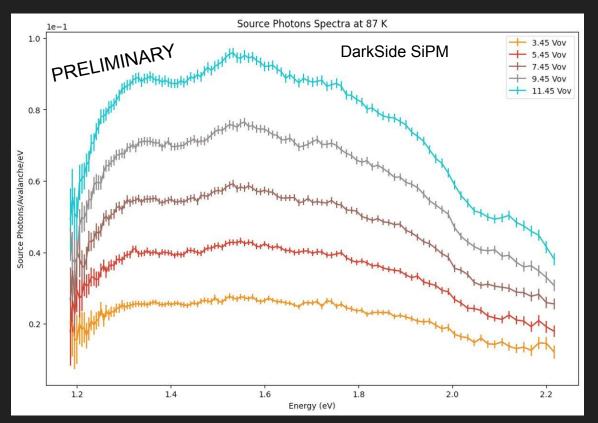


#### Recent Measurements: FBK Darkside

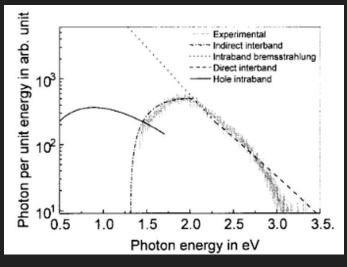




### Source Spectrum: Ansys Lumerical



- Simulate interference effects
- Correct spectra to probe source



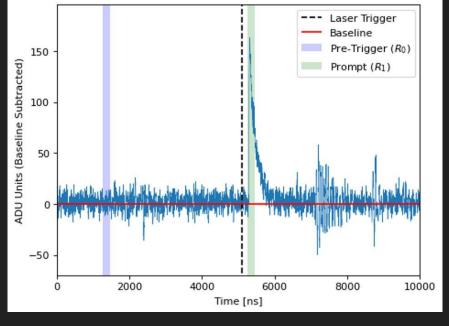
### Analog to Digital

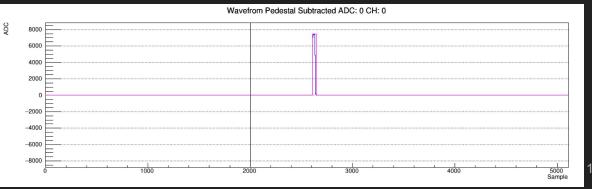
HBK, FBK and DarkSide are analog SiPMs

- All SPADs on single channel
- Analog pulse shape

#### Digital SiPM

- Control each SPAD individually
- Square pulse signal

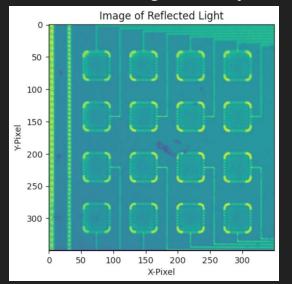


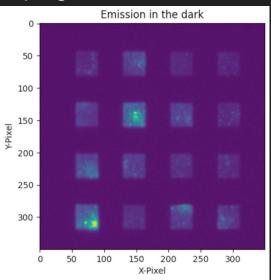


#### Photon Digital Converter

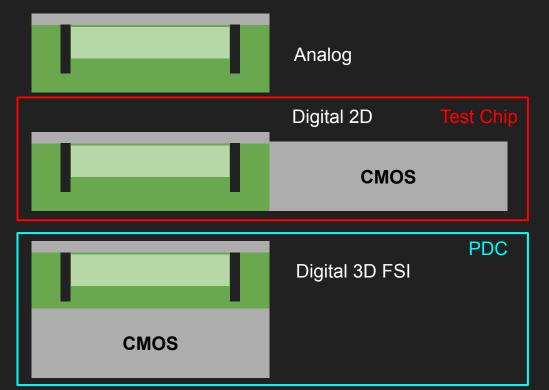
#### Biggest advantage for us:

- Designed by University of Sherbrooke, Fabricated by Teledyne-DALSA
- Fully understand of geometry and doping → use to validate simulations

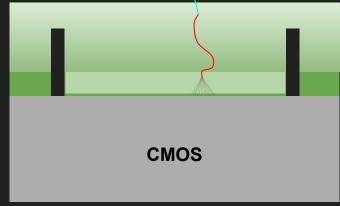




### Improving SPAD Technology



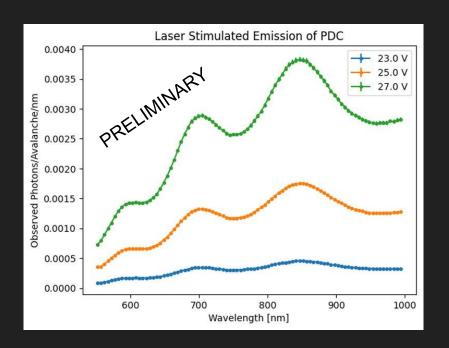
Digital 3D BSI

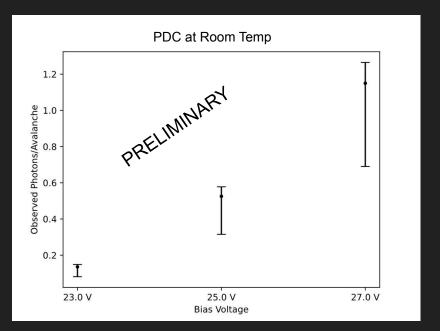


#### Backside Illuminated

- Better Fill Factor
- Single SPAD Readout
- Higher PDE
- Harder to Manufacture (for now)
- Need to optimize design!

### PDC 2D Test Chip Analysis

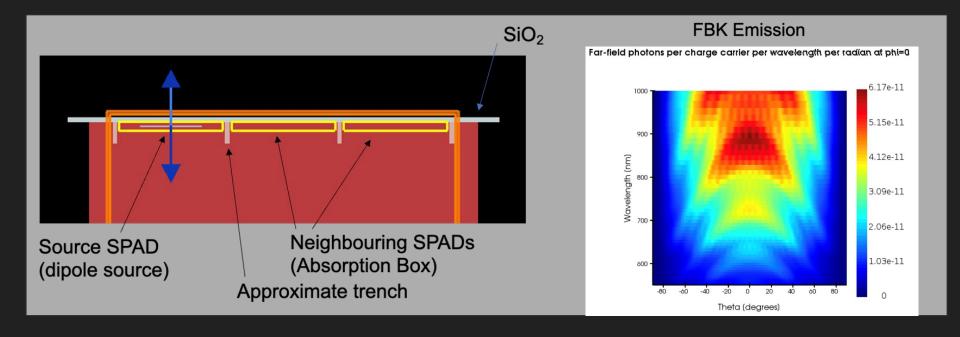




#### Use to Inform Simulation Efforts

Silvaco TCAD – Manufactured Doping and Electric Field

Ansys Lumerical Finite Difference Time Domain – Interference and Emission

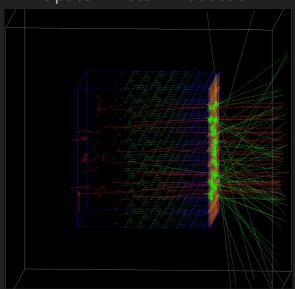


#### **Effective Simulation**

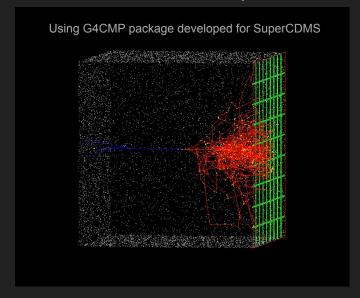
Geant4 might be a solution

From-scratch may be better

**Optical Photon Production** 



#### **Electron Hole Transport**



#### Summary

- MIEL is an effective tool for SiPM characterization

Preliminary characterization of Photon to Digital Converter underway

 PDC can inform simulation work to further SiPM design backside illuminated

CCD

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# Questions? Come work with us!







POUR L'INNOVATION



Photon to Digital Converter Provided by U. de Sherbrooke

#### Back Side Illuminated 3D SPAD

